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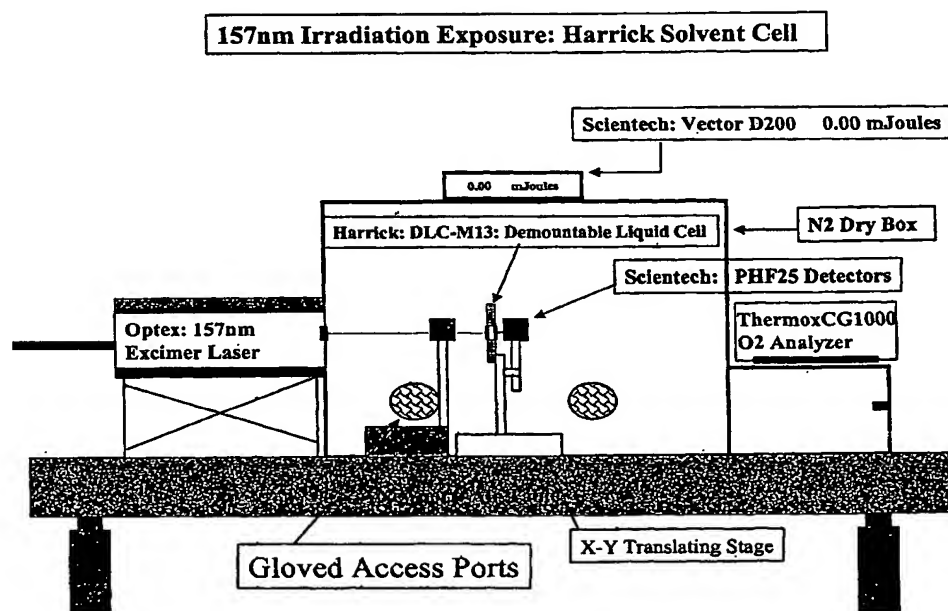
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(54) Title: FLUORINE-CONTAINING COMPOUNDS WITH HIGH TRANSPARENCY IN THE VACUUM ULTRAVIOLET



(57) Abstract: This invention concerns radiation durable organic compositions which are well-suited for use in 157 nm lithography by virtue of their high transparency and excellent radiation durability, and to a process for the preparation thereof.